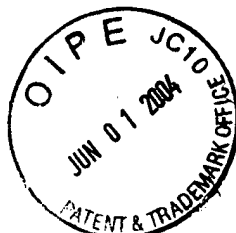


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1FW

TS01-1582B



May 28, 2004

To: Commissioner for Patents
Office of Initial Patent Examination
Customer Service Center
P.O. Box 1450
Alexandria, VA 22313-1450

From: Stephen B. Ackerman

Subject: Serial No.: 10/781,176
Filing Date: 02/18/04
Inventor: C. M. Dai, et al
Title: Full Sized Scattering Bar alt-PSM Technique for IC
Manufacturing in Sub-Resolution ERA

REQUEST TO CORRECT FILING RECEIPT

Dear Sir:

On the copy of the enclosed Filing Receipt, there is an error in the list of Applicants. The third Applicant's residence is misspelled. Mr. You's name and corrected residence reads; Jan-Wen You, **Jungli City**, Taiwan.

Please make the necessary change to correct the error on the Filing Receipt.

If there are any questions, please contact the undersigned attorney at (845) 452-5863. Thank you for your attention to this matter.

Respectfully Submitted,

Stephen B. Ackerman, Reg. No. 37,761

MAY 19 2004

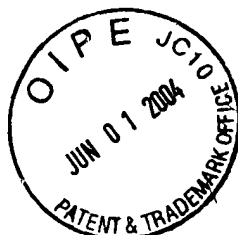


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/781,176	02/18/2004	2182	770	TS01-1582B	7	10	1

George O. Saile
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CONFIRMATION NO. 1817
 FILING RECEIPT



OC000000012681219

Date Mailed: 05/17/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Chang-Ming Dai, Hsinchu, TAIWAN;
 Chung-Hsing Chang, Hsin-Chu City, TAIWAN;
 Jan-Wen You, Jungh City, TAIWAN;
 Burn J. Lin, Hsin chu, TAIWAN; *Ingli*

Assignment For Published Patent Application

TAIWAN SEMICONDUCTOR MANUFACTURING COMPANY;

Domestic Priority data as claimed by applicant

This application is a DIV of 10/205,790 07/26/2002 PAT 6,711,732

Foreign Applications

If Required, Foreign Filing License Granted: 05/15/2004

Projected Publication Date: 08/26/2004

Non-Publication Request: No

Early Publication Request: No

Title

Full sized scattering bar alt-PSM technique for IC manufacturing in sub-resolution ERA

Preliminary Class

710

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